

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:)
Shunpei YAMAZAKI et al.)
Serial No. 09/466,828) Group Art Unit: 2818
Filed: December 20, 1999) Examiner: R. Berry
For: INSULATING FILM AND METHOD OF)
PRODUCING SEMICONDUCTOR DEVICE)

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OFFICE OF PETITIONS

Commissioner for Patents and Trademarks
Washington, D.C. 20231

Sir:

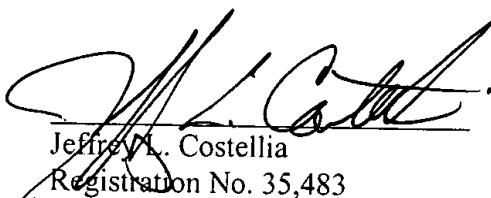
In accordance with the provisions of 37 C.F.R. 1.56 and 37 C.F.R. 1.97-1.99, it is requested that the references listed on the attached Form PTO-1449 be made of record in the above-identified application.

The references listed on the attached Form PTO-1449 were cited in counterpart Japanese applications on April 23, 2002. Copies of the references are submitted herewith in accordance with 37 C.F.R. 1.98(a).

JP 04-295826 teaches the use of quartz or a single crystal silicon as a target for forming a gate insulating film. U.S. Patent No. 5,585,949 is in the same family as JP 04-295826.

The Commissioner is hereby authorized to charge fees under 37 C.F.R. §§1.16, 1.17, 1.20(a), 1.20(b), 1.20(c), and 1.20(d) (except the Issue Fee) which may be required now or hereafter, or credit any overpayment to Deposit Account No. 19-2380 (740756-2077).

Respectfully submitted,



Jeffrey L. Costellia
Registration No. 35,483

NIXON PEABODY LLP
8180 Greensboro Drive, Suite 800
McLean, Virginia 22102
(703) 790-9110

Form PTO-1449
(Rev. 8-83)U.S. Department of Commerce
Patent and Trademark Office

Atty Docket 0756-2077

Serial No. 09/466,828

INFORMATION DISCLOSURE STATEMENT

Applicants: Shunpei YAMAZAKI et al.

Filing Date: December 20, 1999

Group Art Unit: 2818

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date (if appropriate)
	5,585,949	12/17/1996	Yamazaki et al.			

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes No
	04-295826	10/20/1992	JP			Eng Abst

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Examiner	Date Considered
*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	